

Anisotropic thermal conductivity in single crystal β -gallium oxide

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The thermal conductivities of β -Ga₂O₃ single crystals along four different crystal directions were measured in the temperature range of 80–495 K using the time domain thermoreflectance method. A large anisotropy was found. At room temperature, the [010] direction has the highest thermal conductivity of 27.0 ± 2.0 W/mK, while that along the [100] direction has the lowest value of 10.9 ± 1.0 W/mK. At high temperatures, the thermal conductivity follows a $\sim 1/T$ relationship characteristic of Umklapp phonon scattering, indicating phonon-dominated heat transport in the β -Ga₂O₃ crystal. The measured experimental thermal conductivity is supported by first-principles calculations, which suggest that the anisotropy in thermal conductivity is due to the differences of the speed of sound along different crystal directions. © 2015 AIP Publishing LLC.

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β -Ga₂O₃ is a wide-bandgap semiconductor with a bandgap of ~ 4.8 eV.¹ Because of the large bandgap and the resultant large electrical breakdown strength, this material can sustain large voltages, making it attractive for high voltage device applications. Recently, β -Ga₂O₃ Schottky diodes with large reverse breakdown voltages and β -Ga₂O₃ field-effect transistors sustaining large drain voltages have been demonstrated.^{1–4} In a high-voltage device, most of the power is dissipated in the channel, causing an increase in the channel temperature. Such Joule heating can increase the channel temperature by tens or even over one hundred degrees above ambient temperature if heat is not removed efficiently. High temperatures result in the degradation of the electron transport properties due to increased electron-phonon scattering, resulting in the loss of device performance. Efficient removal of the generated heat is required for maintaining the performance, and also for ensuring the reliability of the device. β -Ga₂O₃ crystallizes in a highly anisotropic monoclinic crystal structure with the space group C2/m and lattice constants of $a = 12.214$ Å, $b = 3.0371$ Å, $c = 5.7981$ Å, and $\beta = 103.83^\circ$.⁵ Because of this crystalline anisotropy, the thermal conductivity in β -Ga₂O₃ is expected to be different along different crystal directions. The knowledge of the anisotropic thermal transport in β -Ga₂O₃ at intermediate and high temperatures is of high importance for high-voltage device design for optimal thermal management. However, currently this anisotropic aspect of thermal transport in β -Ga₂O₃ is poorly understood.

Handwerg *et al.* have recently reported the temperature-dependent thermal conductivity of Mg-doped and undoped β -Ga₂O₃ bulk crystals from 4 K to room temperature using

3 ω -method.⁶ The thermal conductivity determined was along the [100] direction. Along this direction, the thermal conductivity at room temperature was found to be 13.0 ± 1.0 W/mK and a peak thermal conductivity of about $(5.3 \pm 0.6) \times 10^2$ W/mK was found at 25 K. Laser-flash methods were used previously to measure thermal conductivity values of 13 W/mK along the [100] direction⁷ and 21 W/mK along the [010] direction.⁸ These values are for room temperature. Typical high-voltage device design requires knowledge of the high-temperature thermal conductivity, which is not yet explored.

In this work, we use time domain thermoreflectance (TDTR) to study the thermal conductivity of β -Ga₂O₃ single crystals along four different crystal orientations: [001], [100], [010], and [-201] over a large temperature range, including much higher temperatures than previous studies. We find a significant anisotropy along the four directions at all temperatures. The [100] direction has the smallest thermal conductivity among all directions, at 10.9 ± 1.0 W/mK at room temperature. The thermal conductivity along the [010] direction is significantly higher—the value 27.0 ± 2.0 W/mK is about three times of that along the [100] direction. The temperature-dependent thermal conductivities at high temperature for all directions show a $1/T$ relationship, indicating the phonon-dominant nature of the thermal transport.

For this study, bulk β -Ga₂O₃ crystals with four crystal orientations ([001], [100], [010], and [-201]) were obtained from Tamura Corporation (Japan). These crystals were grown by an edge-defined film fed growth (EFG) method. The bulk single-crystals were doped with Sn during growth, resulting in a room-temperature carrier concentration of $\sim 5\text{--}6 \times 10^{18}$ cm⁻³. The crystal orientations of the samples were verified using X-ray diffraction measurements.³¹ The

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X-ray diffraction measurements directly verify the high crystallinity and orientation of the β -Ga₂O₃ single crystals. A 100 nm-thick Al film (nominal thickness) was then deposited using electron beam evaporation on top of the Ga₂O₃ crystals for TDTR measurements. The actual film thickness was of 103 ± 5 nm determined by profilometry (KLA-Tencor, P6).

The TDTR system used for the thermal conductivity measurements was described elsewhere.^{9,10} The $1/e^2$ radii (where beam diameter is defined by the intensity falls to $1/e^2 = 0.135$ times the maximum value) of the pump and probe beams incident on the Al film surface were $30 \mu\text{m}$ and $5 \mu\text{m}$, respectively. The modulation frequency of the pump beam was set to 5 MHz for all measurements. For temperature-dependent measurements, a liquid nitrogen-cooled cryogenic system (ST-100, Janis Research) with a temperature-control module (Lakeshore Ltd.) was used to cool or to heat the sample and stabilize the sample at target temperatures. To monitor the actual temperature on the sample surface, a calibrated silicon diode (DT-670-SD) was attached to the sample surface and connected to the temperature controller. The setup described above allows us to investigate the temperature range from 80 K to 495 K with a 0.01 K precision.

To extract the thermal conductivity from the thermoreflectance decay data, the phase signal data demodulated from the lock-in amplifier were used to fit a pulse-accumulated heat conduction model.¹¹ To obtain the thermal conductivity, it is necessary to know the heat capacity of Ga₂O₃ at different temperatures. Since this data are not available in the literature, we have performed the measurement of heat capacity of β -Ga₂O₃ crystals in the temperature range of 123 K–748 K, using a differential scanning calorimeter (Mettler Toledo, DSC-1). The measured temperature-dependent specific heat capacity is shown in Figure 1. The data are fitted to the Debye model of the specific heat

$$C(T) = 3Nk \frac{3}{x_0^3} \int_0^{x_0} \frac{x^4 e^x}{(e^x - 1)^2} dx, \quad (1)$$

where $x_0 = \frac{\hbar \omega_D}{kT} = \frac{\theta_D}{T}$. Here θ_D is the Debye temperature, T is the absolute temperature, \hbar is the reduced Planck's constant, and k is the Boltzmann constant. In Eq. (1), N is the number of atoms in the sample. Since each formula unit of Ga₂O₃ has five atoms, each mole of Ga₂O₃ formula units (~ 187.438 g of

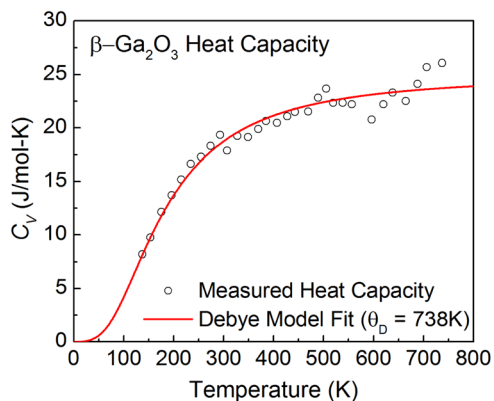


FIG. 1. Measured heat capacity of β -Ga₂O₃ as a function of temperature. The solid line is the Debye model fit from which the Debye temperature is obtained.

β -Ga₂O₃) has five moles of atoms. Measured data, as shown in Figure 1, have been normalized to one mole of atoms ($N = 6.023 \times 10^{23}$). From the fit in Figure 1, the Debye temperature is obtained as 738 K, in reasonable agreement with a predicted value of 872 K from first-principles calculations.¹² With these values of the heat capacity, the thermal conductivity is extracted from the TDTR measurements.

Since the laser beam sizes used for our TDTR measurements are much larger than the thermal penetration depth, one-dimensional heat transfer into the surface can be assumed. As a result, samples with different crystalline orientations allow us to directly probe the thermal transport along specific crystal directions. Through TDTR measurements, the temperature-dependent thermal conductivity measured along different directions at various temperatures are shown in Figure 2. The thermal conductivity is the highest along the [010] direction, and lowest along the [100] direction at all temperatures used in the measurements. The thermal conductivity in the [100] direction is consistent with Handberg's report,⁶ with the value increasing from ~ 10 W/mK by roughly an order of magnitude around 100 K. The thermal conductivity along crystal orientations of smaller lattice constant is larger, as indicated in the inset of Figure 2(a).

As a wide-bandgap semiconductor, a major part of the thermal conductivity of Ga₂O₃ is expected to be due to crystal vibrations (phonons) with a small contribution from free carriers. Although the samples are doped with Sn with a concentration of $\sim 5\text{--}6 \times 10^{18} \text{ cm}^{-3}$, the mobile electron contribution to thermal conductivity is negligible when the carrier concentration is lower than 10^{19} cm^{-3} .¹³ At high-temperatures approaching the Debye temperature, umklapp scattering is the dominant phonon scattering mechanism in a near-perfect crystal with low density of defects. Therefore, we focus our analysis in the high temperature region. In this regime, the specific heat capacity $c_v = \frac{C_v}{V}$ of phonons saturates according to the Dulong-Petit law: Figure 1 shows the heat capacity approaching a high-temperature saturation value of ~ 25 J/mol-K. The thermal conductivity $\kappa \simeq \frac{1}{3}(v_s l)c_v$ at high temperatures depends on the sound velocity v_s and the mean-free path l of phonons. Because the relaxation time of acoustic phonons decreases as $1/T$ due to the increase in the phonon density, according to kinetic theory, the thermal conductivity at high temperatures should follow a $1/T$ relationship. In practice, this relationship often exhibits $1/T^m$ ($m = 1\text{--}1.5$) behavior.¹⁴ We fit the high temperature data (>350 K) to a $1/T^m$ relation in Figure 2 as dashed lines. As can be seen, the relation fits the thermal conductivities reasonably well at high temperatures. The fit extends down to 200 K, well below the Debye temperature. For convenience in device modeling with a few parameters, we fit the thermal conductivity in the whole temperature range using $\kappa(T) = AT^{-m}$ in two different temperature regimes (80–200 K and 200–495 K), and present the parameters in Table I. As shown in Table I, for high temperature region (200–495 K), the index m in $1/T^m$ are all around 1 for all the directions.

If we assume a gray model for phonon transport (i.e., all phonons have the same group velocity and relaxation time), the thermal conductivity in a specific direction, i , can be expressed as^{14,15}

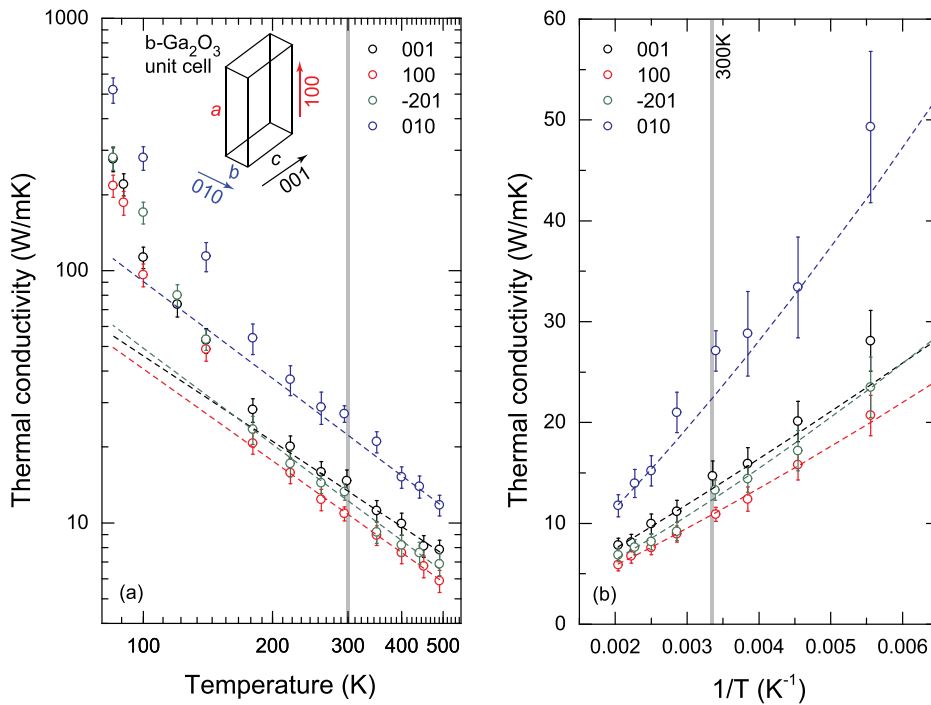


FIG. 2. Temperature-dependent thermal conductivity of β - Ga_2O_3 measured along different crystal directions by the TDTR approach. In (a), the thermal conductivity and temperature are in the log scale. The inset shows a schematic of the unit cell of the β - Ga_2O_3 crystal. The thermal conductivity is larger along directions of smaller lattice constant: The rough lattice constant ratios are $c \sim 2b$ and $a \sim 4b$. The dashed lines show $1/T^m$ fits that capture the high-temperature behavior of the thermal conductivity. The vertical dashed line separates the high-temperature behavior from the lower-temperature deviation to the fits. (b) Shows a linear plot of thermal conductivity against $1/T$ to highlight the dependence on temperature and the high-temperature $1/T^m$ fits more clearly.

$$\kappa_i = c_v(v_i \cdot v_i)\tau, \quad (2)$$

where c_v denotes the volumetric heat capacity, v_i is the group velocity in the direction i ($=x,y,z$), and τ is relaxation time. In the gray model, the phonon group velocity is usually approximated by the sound speed. Since both c_v and τ are scalars, the orientation-dependent group velocity v thus solely determines the anisotropy of the thermal conductivity. This is also confirmed by experiments: the thermal conductivity along different directions can be approximately related to each other by a multiplication factor at high temperature (>200 K). Such a factor is related to the magnitude of the square of the sound speed in different directions. We can therefore obtain the relative sound speeds (normalized to that in the [001] direction) from the temperature dependent thermal conductivity data (Table II).

We further calculate the phonon dispersion relation of β - Ga_2O_3 using Density Functional Perturbation Theory (DFPT)¹⁶ to extract the phonon group velocities at different directions to justify the experimental findings. In Figure 3, we plot the acoustic phonon dispersion relationship calculated from a 10-atom primitive cell along four specified directions using the PWscf and PHonon modules of the Quantum Espresso package.¹⁷ The Perdew-Burke-Ernzerhof functional, and norm-conserving pseudopotentials were

TABLE I. A functional form of $\kappa(T) = AT^{-m}$ is used to fit the temperature dependent thermal conductivity data in two temperature ranges (range 1: 80–200 K and range 2: 200–495 K). The fitting value of each parameter in the equation has been summarized in four columns (subscripts represent different temperature regions).

Crystallographic orientation	A_1	m_1	A_2	m_2
[001]	1.06×10^{10}	3.93	8.14×10^3	1.12
[100]	1.85×10^9	3.59	1.06×10^4	1.21
[010]	7.99×10^8	3.21	3.28×10^4	1.27
[-201]	8.26×10^8	3.35	1.69×10^4	1.28

used. The plane-wave basis kinetic energy cut-off was set to 60 Ry. A $5 \times 5 \times 3$ k-point mesh was used for Brillouin zone sampling. We note that the phonon band structure obtained in this work are in good agreement with the previous first-principles calculations on β - Ga_2O_3 ,¹⁸ but the dispersion relationship along the specific directions required here was not presented in the prior work. To approximate the sound speed along each specific direction of interest, we calculate the slopes of each acoustic branch in that direction near the Brillouin zone center and take the average of the square, i.e., $\bar{v}^2 = \frac{1}{3}(v_L^2 + v_{T1}^2 + v_{T2}^2)$.

In Table II, we find that the predicted phonon speeds from first-principles calculations show a very similar trend as that extracted from the experimental data. However, there are quantitative differences. This can be attributed to two reasons. (1) Strictly speaking, the relative speed extracted using Eq. (2) from the experimental data is not the speed of sound. Instead, what we obtain is the effective phonon group velocity weighted by factors related to the specific heat and

TABLE II. A comparison of the relative sound speed determined from thermal conductivity measurements and predicted sound speed from first-principles calculations. The sound speed values are normalized to the value along [001] direction. The linear regime of Figure 3 was fitted and used to obtain the group velocity of each branch. V_L represents the LA phonon group velocity and V_T denotes the group velocity of two TA phonon branches.

Crystallographic orientation	Relative sound speed determined by experiments	Approximate mean sound speed from first-principles calculations	Absolute group velocity from first-principles calculations (10^5 cm/s)
[001]	1.00	1.00	7.1 (V_L) 2.8–3.1 (V_T)
[100]	0.88 ± 0.2	0.91	5.4 (V_L) 3.4–3.9 (V_T)
[010]	1.32 ± 0.25	1.13	7.8 (V_L) 3.0–4.1 (V_T)
[-201]	0.94 ± 0.26	0.93	6.6 (V_L) 2.4–3.1 (V_T)

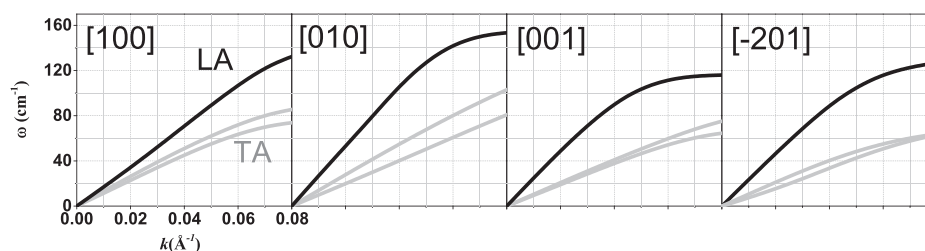


FIG. 3. Phonon dispersion relationship calculated along four different directions. For clarity, in each direction, only three acoustic phonon branches are shown. The LA modes are shown in black, while the TA modes are colored in grey. The Miller indices use the unit cell lattice vector definitions in order to compare with the experimental findings.

relaxation time of all the phonon modes. (2) We have ignored the contributions of optical phonons to the thermal conductivity when using the acoustic phonon group velocities the first-principles calculations to approximate sound speeds. Nevertheless, since the acoustic phonons with long wavelengths are usually major contributors to the overall thermal conductivity in semiconductor crystals,^{19–23} we are still able to qualitatively explain the experimentally observed trend using the first-principles phonon group velocities.

It is interesting to compare the thermal conductivity of Ga_2O_3 to GaN, which has been a widely used semiconductor for power electronic applications. GaN has a thermal conductivity of 130–230 W/mK at room temperature,^{24–26} and isotopically enriched GaN can have thermal conductivity up to 400 W/mK according first-principles calculations.²⁷ These values are much higher than that of the Ga_2O_3 , which is in the range of 10–30 W/mK. According to the gray model (Eq. (2)), difference in c_v , v , and τ can lead to the difference in thermal conductivity between Ga_2O_3 and GaN. However, we found that the LA and TA mode group velocities of $\beta\text{-Ga}_2\text{O}_3$ (Table II) are not significantly different from the reported values of GaN ($V_L = 6.9 \times 10^5$ – 8.2×10^5 cm/s and $V_T = 3.3 \times 10^5$ – 5.0×10^5 cm/s along different directions),²⁸ and meanwhile, their volumetric heat capacities differ by less than 20%.²⁹ It implies that a phonon relaxation time τ in GaN is much larger than that in Ga_2O_3 . The phonon relaxation time depends on the anharmonicity of the crystal and the chance they can be scattered by another two phonons—the three phonon scattering process. The anharmonicity can be characterized using the Grüneisen parameters and the three-phonon scattering phase space characterize the likelihood of scattering. Those parameters were obtained from our first-principles calculations (Table III). (for details, see Ref. 31) In Table III, we found that the Grüneisen parameters of the acoustic branches in Ga_2O_3 are comparable to GaN. We only compared the acoustic branches since we have assumed that they are the main contributors to the thermal

conductivity. However, the three-phonon scattering phase space of Ga_2O_3 is much larger than that of GaN. This implies that the three phonon scattering should be much stronger in Ga_2O_3 and shall result in a lower thermal conductivity. This conclusion is supported by the previous first-principles thermal conductivity calculations:^{27,30} the high thermal conductivity of GaN is attributed to the weak phonon-phonon umklapp scattering due to a large gap in its phonon band structure compared to other gallium compounds. In Ga_2O_3 , such a gap is significantly smaller, and thus, the phonon scattering is expected to be stronger, which leads to a much shorter relaxation time.

In conclusion, we find highly anisotropic thermal conductivity in $\beta\text{-Ga}_2\text{O}_3$ single crystals using TDTR measurements over a large temperature range, specifically at high temperatures. Among the directions investigated, the [010] direction has the highest thermal conductivity and that along the [100] direction is the lowest. At high temperatures, the thermal conductivity generally follows a $1/T$ relationship, indicating a phonon-dominated thermal transport. The anisotropy in the phonon group velocities explains the observed thermal conductivity anisotropy. The thermal conductivity data will be helpful for the thermal management and design of Ga_2O_3 -based devices.

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TABLE III. A comparison of acoustic phonon Grüneisen parameters and the three-phonon scattering phase space volume in Ga_2O_3 and GaN.

	Grüneisen parameter of acoustic branches	Normalized scattering phase space volume
Ga_2O_3	−1.06 (TA1), −0.30 (TA2), 0.83 (LA)	1200
GaN	−0.86 (TA1), −0.86 (TA2), 0.51 (LA)	38

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